

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	18	(amorphous adj silicon) near5 (physical adj vapor adj deposition)	USPAT	2002/04/03 15:14
2	BRS	L2	10	1 same (annealing or anneal or heating or heat or thermal)	USPAT	2002/04/03 15:14
3	BRS	L5	1	2 same laser	USPAT	2002/04/03 15:16
4	BRS	L7	9	2 not 5	USPAT	2002/04/03 15:16